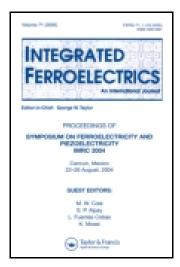
This article was downloaded by: [University of Otago]

On: 08 September 2014, At: 23:06

Publisher: Taylor & Francis

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-41 Mortimer Street, London W1T 3JH,

UK



# Integrated Ferroelectrics: An International Journal

Publication details, including instructions for authors and subscription information: <a href="http://www.tandfonline.com/loi/ginf20">http://www.tandfonline.com/loi/ginf20</a>

# A Ferroelectric Capacitor Mathematical Model for Spice Simulation

CHAO-GANG WEI  $^{\rm a}$  , TIAN-LING REN  $^{\rm a}$  , JUN ZHU  $^{\rm a}$  & LI-TIAN LIU  $^{\rm a}$ 

<sup>a</sup> Institute of Microelectronics Tsinghua University, Beijing, China, 100084

Published online: 11 Aug 2010.

To cite this article: CHAO-GANG WEI, TIAN-LING REN, JUN ZHU & LI-TIAN LIU (2004) A Ferroelectric Capacitor Mathematical Model for Spice Simulation, Integrated Ferroelectrics: An International Journal, 64:1, 101-111, DOI: 10.1080/10584580490893691

To link to this article: <a href="http://dx.doi.org/10.1080/10584580490893691">http://dx.doi.org/10.1080/10584580490893691</a>

#### PLEASE SCROLL DOWN FOR ARTICLE

Taylor & Francis makes every effort to ensure the accuracy of all the information (the "Content") contained in the publications on our platform. However, Taylor & Francis, our agents, and our licensors make no representations or warranties whatsoever as to the accuracy, completeness, or suitability for any purpose of the Content. Any opinions and views expressed in this publication are the opinions and views of the authors, and are not the views of or endorsed by Taylor & Francis. The accuracy of the Content should not be relied upon and should be independently verified with primary sources of information. Taylor and Francis shall not be liable for any losses, actions, claims, proceedings, demands, costs, expenses, damages, and other liabilities whatsoever or howsoever caused arising directly or

indirectly in connection with, in relation to or arising out of the use of the Content.

This article may be used for research, teaching, and private study purposes. Any substantial or systematic reproduction, redistribution, reselling, loan, sub-licensing, systematic supply, or distribution in any form to anyone is expressly forbidden. Terms & Conditions of access and use can be found at <a href="http://www.tandfonline.com/page/terms-and-conditions">http://www.tandfonline.com/page/terms-and-conditions</a>

Copyright © Taylor & Francis Inc. ISSN: 1058-4587 print/ 1607-8489 online DOI: 10.1080/10584580490893691



# A Ferroelectric Capacitor Mathematical Model for Spice Simulation

CHAO-GANG WEI, TIAN-LING REN, JUN ZHU, and LI-TIAN LIU

Institute of Microelectronics, Tsinghua University, Beijing 100084, China

(Received April 29, 2004; In final form June 3, 2004)

A behavioral ferroelectric capacitor model based on Q-V expression with model parameters extracted from experimental hysteresis loops is proposed. A compact equivalent circuit of this model is described for spice simulation of nonvolatile memories. Excellent agreement was achieved between our measurements and simulation results. The runtime for simulation of a hysteresis loop with 10,000 points is 1.55 seconds, which is similar to 1.15 seconds for a normal capacitor.

Keywords: ferroelectric capacitor; Q-V expression; hysteresis loop; equivalent circuit

#### INTRODUCTION

In recent years ferroelectric random access memories (FeRAMs) have attracted considerable attention as a possible next generation nonvolatile memory technology due to the benefits of small cell size, low voltage operation, fast access time and high read/write endurance with nonvolatile data storage [1, 2]. An accurate model expressing the electrical properties of a ferroelectric capacitor is especially important for the design and optimization of ferroelectric memories. There have been many attempts at modeling ferroelectric capacitors, and significant progress has been made [3-6]. However, a compact dynamic ferroelectric capacitor model with high accuracy which can be easily introduced to existing EDA tools is still absent. Some physically based models provide satisfying intuition into the material behavior but are too complicated for simulation by existing EDA tools. Other behavioral models are not consummate enough to be flexible for different ferroelectric capacitors with different parameters. Otherwise, some models spend too long time in simulation, which is disadvantageous for simulation of large scale FeRAMs.

In this paper, we propose a compact mathematical ferroelectric capacitor model with good compatibility to existing circuit simulation tools, fine flexibility for different capacitors with different parameters, short simulation time and sufficient accuracy. The model is based on the mathematical basis of Q-V relationship which are assumed to be determined by the past extremum values of the voltage input and initial polarization. Parameters of the model can be extracted by curve fitting a measured hysteresis loop. The transitions between the loops under different voltage patterns show a high accuracy with measured results over a wide range of operation. The time required for the polarization reversal is substantially fast so that the polarization reversal time of the ferroelectric capacitors does not affect the operational speed of the practical memories [7]. For simplicity, frequency effect caused by dipole switching time delay and other time dependent effects such as polarization fatigue and relaxation are neglected.

#### **MATHEMATICAL BASIS**

## **Q-V Expression for Primary Hysteresis**

The Q-V curve of a ferroelectric capacitor is similar to its P-E (polarization-electric field) hysteresis curve [8]. Thus in point of circuit simulation a ferroelectric capacitor can be regarded as a voltage-controlled nonlinear capacitor whose Q-V relation presents a hysteresis loop.

The Preisach model [9] is an appropriate macroscopic model describing the ferroelectric material as a set of elementary dipoles that contribute to the total polarization. However, it requires the time-consuming numerical evaluation of double integrals. Thus this approach is difficult to be applied for circuit simulation directly. In fact, for generic simulation Q-V expressions can take any functional form as long as they fit the experimental loops. The hyperbolic tangent is often chosen [4, 10]. Here we select the arc tangent as the Q-V expression form because the derivative of the arc tangent is more simply and spends less time in circuit simulation than that of the hyperbolic tangent. And the Q-V expression based on the arc tangent function gives better agreements with our experimental results than that based on the hyperbolic tangent according to our practical simulations.

A saturated hysteresis loop can be divided into two branches as lower branch and upper branch, as illustrated in Fig. 1. The Q-V expressions of the two branches are described as:

$$Q_1(V) = \frac{c}{2a} \left[ arc \tan \left( \frac{V_m + V_c}{a} \right) - arc \tan \left( \frac{V_m - V_c}{a} \right) \right] + \frac{c}{a} \cdot arc \tan \left[ \frac{(V - V_c)}{a} \right] \quad \text{for lower branch}$$
 (1)

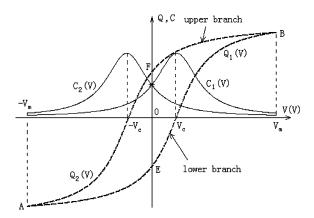


FIGURE 1 Hysteresis loop and C-V curve of a ferroelectric capacitor.

$$Q_2(V) = \frac{c}{2a} \left[ arc \tan \left( \frac{V_m - V_c}{a} \right) - arc \tan \left( \frac{V_m + V_c}{a} \right) \right] + \frac{c}{a} \cdot arc \tan \left[ \frac{(V + V_c)}{a} \right] \quad \text{for upper branch}$$
 (2)

where a, c are curve fitting parameters to be extracted from experimental hysteresis loops.  $V_c$  is the macroscopic coercive voltage of hysteresis loops.

In actual circuit simulation, the total charge or polarization of a ferroelectric capacitor must be calculated by integrating its differential capacitance, which is equal to the derivative of charge on the capacitor electrode with respect to the voltage across the capacitor as illustrated in Fig. 1. According to Eqs. (1) and (2), the C-V expressions are described as:

$$C_1(V) = \frac{dQ_1(V)}{dV} = \frac{c}{a^2 + (V - V_c)^2}$$
 (3)

$$C_2(V) = \frac{dQ_2(V)}{dV} = \frac{c}{a^2 + (V + V_c)^2}$$
(4)

where  $C_1(V)$  is implemented when the capacitor bias changes from  $-V_m$  to  $V_m$ , and  $C_2(V)$  is implemented when the capacitor bias changes from  $V_m$  to  $-V_m$ . The two branches switch to each other when the Q-V curve changes direction or when dV/dt changes sign (see Fig. 1). We import a return sign

function:

$$sgn(x) = -1$$
 (if  $x < 0$ ); or 0 (if  $x = 0$ ); or 1 (if  $x > 0$ ) (5)

Combining Eqs. (3)–(5), C(V) can be written in the uniform expression

$$C(V) = C_1(V) \cdot \frac{[1 + \text{sgn}(dV/dt)]}{2} + C_2(V) \cdot \frac{[1 - \text{sgn}(dV/dt)]}{2}$$
 (6)

# Q-V Expression for Minor Hysteresis Loops Under Arbitrary Bias

From experimental results, when the amplitude of the stimulated voltage decreases from  $V_m$  to  $V_x$ , a minor hysteresis loop (C-G-D-H-C) is generated in the major hysteresis loop (A-E-B-F-A) as illustrated in Fig. 2. We suppose  $Q_1'(V)$  and  $Q_2'(V)$  denote the lower branch and the upper branch of the minor hysteresis loop respectively. Referring to Eqs. (1) and (2),  $Q_1'(V)$  and  $Q_2'(V)$  can be formulated as

$$Q_1'(V) = \frac{c'}{2a} \left[ arc \tan \left( \frac{V_x + V_c}{a} \right) - arc \tan \left( \frac{V_x - V_c}{a} \right) \right] + \frac{c'}{a} \cdot arc \tan \left[ \frac{(V - V_c)}{a} \right]$$
(7)

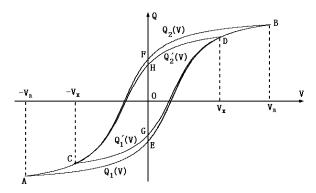


FIGURE 2 The transition between the major loop (A-E-B-F-A) and a minor loop (C-G-D-H-C).

$$Q_2'(V) = \frac{c'}{2a} \left[ arc \tan \left( \frac{V_x - V_c}{a} \right) - arc \tan \left( \frac{V_x + V_c}{a} \right) \right] + \frac{c'}{a} \cdot arc \tan \left[ \frac{(V + V_c)}{a} \right]$$
(8)

where c' is described as

$$c' = \frac{c \cdot \left[ arc \tan\left(\frac{V_m + V_c}{a}\right) - arc \tan\left(\frac{V_m - V_c}{a}\right) + 2 \cdot arc \tan\left(\frac{V_x - V_c}{a}\right) \right]}{arc \tan\left(\frac{V_x + V_c}{a}\right) + arc \tan\left(\frac{V_x - V_c}{a}\right)} \tag{9}$$

The C-V expression for the minor hysteresis loop generated by stimulation of voltages with amplitude of  $V_x$  is formulated as

$$C'(V) = C'_1(V) \cdot \frac{[1 + \operatorname{sgn}(dV/dt)]}{2} + C'_2(V) \cdot \frac{[1 - \operatorname{sgn}(dV/dt)]}{2}$$
 (10)

where

$$C_1'(V) = \frac{c'}{a^2 + (V - V_c)^2} \tag{11}$$

$$C_2'(V) = \frac{c'}{a^2 + (V + V_c)^2}$$
 (12)

where c' is described as Eq. (9), and  $V_x$  is an arbitrary positive number denoting the amplitude of the arbitrary biases across the ferroelectric capacitor. The remnant polarization corresponding to stimulation of voltage with the amplitude of  $V_x$  is given as

$$Q'_{r|Vx} = \pm \frac{c'}{2a} \left[ arc \tan \left( \frac{V_x - V_c}{a} \right) - arc \tan \left( \frac{V_x + V_c}{a} \right) + 2 \cdot arc \tan \left( \frac{V_c}{a} \right) \right]$$
(13)

A ferroelectric capacitor in a FeRAM cell is always history dependent and remains remnant polarization state before operation. The initial remnant polarization can be specified by setup of the initial voltage across the ferroelectric capacitor as below:

$$V_{init} = init \cdot \frac{\left(a^2 + V_c^2\right)}{2a} \cdot \left[arc \tan\left(\frac{V_x - V_c}{a}\right) - arc \tan\left(\frac{V_x + V_c}{a}\right) + 2 \cdot arc \tan\left(\frac{V_c}{a}\right)\right]$$
(14)

here init = 1 when the capacitor is polarized to positive state or init = -1 when the capacitor is polarized to negative state.

#### MACROMODEL FOR SPICE SIMULATION

A circuit representation of this mathematical model with the input port in+ and in- is shown in Fig. 3.  $C_x$  is a voltage-controlled nonlinear capacitor with the capacitance expressed by Eq. (10), which is the core to represent the nonlinear and hysteretic characteristics of the ferroelectric capacitor. Some other behavioral elements are used in the equivalent circuit serving as control portion. We define  $V_f$  as the voltage bias across the ferroelectric capacitor. Ecap is a voltage-controlled voltage source to transform  $V_f$  into the voltage of node cout. Gswitch is a voltage-controlled switch with the controlling voltage of  $V_{dout}$ , which is opened only when  $V_{dout}$  is near zero in a little range  $(-\delta V, \delta V)$ . Ecomp is an ideal op-amp element. Ecomp and Capacitor c1, Resistor r1 form a differential circuit for differential operation of  $V_{cout}$ 

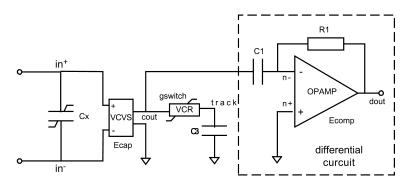


FIGURE 3 A circuit representation of the mathematical ferroelectric capacitor model.

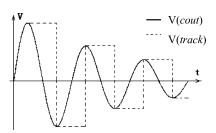


FIGURE 4 V(track) keeps the last extremum of the capacitor biases.

to  $V_{dout}$ :

$$V_{dout} = -R_1 C_1 \frac{dV_{cout}}{dt} = -R_1 C_1 \frac{dV_f}{dt}$$
 (15)

Though the voltage bias across the ferroelectric capacitor is continuously changing, Gswitch and Capacitor c3 enable the node of *track* to keep the last extremum of the voltage biases, as illustrated in Fig. 4. Therefore, V(*track*) is regarded as the amplitude of the arbitrary biases applied to the ferroelectric capacitor. In the input netlist file for simulation Eq. (9) becomes

$$c' = \frac{c \cdot \left[ arc \tan \left( \frac{V_m + V_c}{a} \right) - arc \tan \left( \frac{V_m - V_c}{a} \right) + 2 \cdot arc \tan \left( \frac{V_{track} - V_c}{a} \right) \right]}{arc \tan \left( \frac{V_{track} + V_c}{a} \right) + arc \tan \left( \frac{V_{track} - V_c}{a} \right)}$$

$$(16)$$

FIGURE 5 P-V hysteresis loops measured at different voltages from a PZT capacitor. (See color plate IV)

V (Volts)

10

15

-5

-15

-10

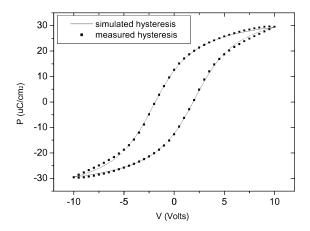


FIGURE 6 Simulated and measured hysteresis loop at 10 V.

## SIMULATION RESULTS AND DISCUSSIONS

The ferroelectric capacitor samples were prepared by sol-gel method with Pt electrodes of  $100 \times 100~\text{um}^2$  size fabricated by RIE (Reactive Ion Etching) and PZT dielectric thickness of about 400 nm. Figure 5 shows the measured hysteresis loops by stimulation of triangular waveforms at different voltages.

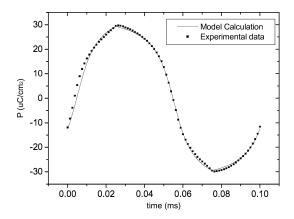


FIGURE 7 Simulated and measured polarization-time curve at 10 V.

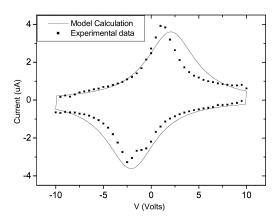


FIGURE 8 Simulated and measured current-voltage curve at 10 V.

The parameters extracted by curve fitting the measured hysteresis at 10 V is:  $a=3.1024,\ V_m=10,\ V_c=2.08677,\ c=A*0.7236,\ where\ A$  is the area of ferroelectric capacitor. Figure 6 shows the comparison between simulated and measured hysteresis loop at 10 V by Sawyer-Tower circuit. Figure 7 shows the comparison between simulated and measured Polarization-Time curve during a period of triangular stimulated waveform. Comparison between simulated and measured Current-Voltage relationship is shown in Fig. 8. Some disagreement exists in Fig. 8 between simulation

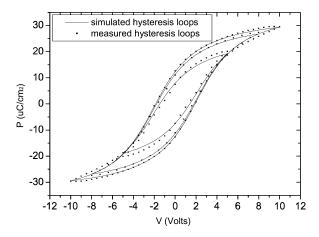


FIGURE 9 Simulated and measured hysteresis loops at 10 V, 8 V and 5 V.

and experiment probably due to measurement error and neglect of dipole switching time.

A set of hysteresis loops at different voltages of 10 V, 8 V and 5 V were simulated and compared with experimental results in Fig. 9. The transitions between the simulated loops show good agreement with experimental data.

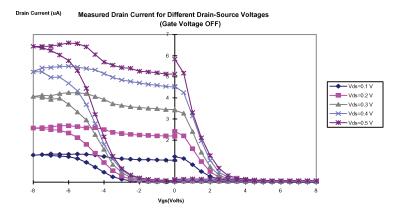
#### CONCLUSION

Based on the above agreement, we conclude that the complex behavior and history dependence of a ferroelectric capacitor can be described as a voltage-controlled nonlinear capacitor with behavioral elements as control portion. This compact model is conveniently introduced to existing tools such as Spice for FeRAM circuit simulation with short simulation runtime. The model will demonstrate high accuracy and good agreement with actual ferroelectric capacitors in circuit simulation as long as the Q-V (or C-V) mathematical expression is adequately precise. Based on this mathematical model, future enhancement is easily imported to handle dynamic responses and other higher-order effects, such as imprint, fatigue, and asymmetry of hysteresis loops due to various defects.

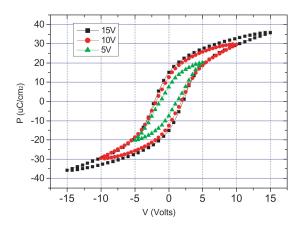
## REFERENCES

- J. F. Scott and C. A. Araujo, Paz de: Ferroelectric memories. Science 246, 1400–1405 (1989).
- [2] J. T. Evans and R. Womack, An experimental 512-bit nonvolatile memory withy ferroelectric storage cell. *IEEE J Solid-State Circuits* 23(5), 1171–1175 (1989).
- [3] S. L. Miller, R. D. Nasby, J. R. Schwank, M. S. Rodgers, and P. V. Dressendorfer, Device modeling of ferroelectric capacitors. J. Appl. Phys. 68(12), 6463–6471 (1990).
- [4] S. L. Miller, J. R. Schwank, R. D. Nasby, and M. S. Rodgers, Modeling ferroelectric capacitor switching with asymmetric nonperiodic input signals and arbitrary initial conditions. J. Appl. Phys. 70(5), 2849–2860 (1991).
- [5] A. Sheikholeslami and Gulak P. Glenn, Transient modeling of ferroelectric capacitors for nonvolatile memories. *IEEE Trans Ultrason, Ferroelect, Freq. Contr.* 43, 450–456 (1996).
- [6] C. X. Li, T. L. Ren, and W. Q. Zhang, An improved behavioral model of ferroelectric capacitors. *Integrated Ferroelectrics* 40(1–5), 1491–1498 (2001).
- [7] A. Seike, K. Amanuma, S. Kobayashi, T. Tatsumi, H. Koike, and H. Hada, Polarization reversal kinetics of a lead zirconate titanate thin-film capacitor for nonvolatile memory. *J. Appl. Phys.* 88(6), 3445–3447 (2000).

- [8] B. Tareev, Physics of Dielectric Materials. Moscow: Mir Publishers (1975).
- [9] I. Mayergoyz, Mathematical Models of Hysteresis. New York: Springler (1991).
- [10] B. Jiang, P. Zurcher, R. E. Jones, S. J. Gillespie, and J. C. Lee, Computationally efficient ferroelectric capacitor model for circuit simulation. *Symposium on VLSI Technology*. *Digest of Technical Papers*, pp. 141–142 (1997).



**Color Plate III.** See Figure 9 on page 98.—Measured drain current for Remnant mode.



**Color Plate IV.** See Figure 5 on page 108.—P-V hysteresis loops measured at different voltages from a PZT capacitor.